**DuPont™ EKC922™ Universal Photoresist Remover**

**Product Description**
DuPont™ EKC922™ universal photoresist remover is an organic based photoresist remover formulated to remove positive and negative photoresist and other organic compounds where an ultra clean surface is required.

**Advantages**
- No phenol or chlorinated solvents
- Extended bath life
- Compatible with III to V compound semiconductors (i.e., GaAs, InP and SiGe)
- Safe to use on semi-cured polyimides
- Compatible with conventional semiconductor materials

**Typical Applications**
Bulk photoresist removal for:
- MEMS
- Backlap process
- Chrome photomasks
- Metal carriers
- Ink dot removal
- Integrated circuits
- Hybrid device
- III–V compound semiconductors
- Spinner parts
For more information on DuPont™ EKC922™ or other DuPont products, please visit our website.

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